

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Hisatsugu KURITA et al.

Title: SILICON WAFER CLEANING METHOD

Patent. No.: 7,226,513

Issue Date: 06/05/2007

Examiner: Michail Kornakov

Art Unit: 1746

Confirmation Number: 8557

Certificate

AUG 02 2007

of Correction

REQUEST FOR CERTIFICATE OF CORRECTION FOR
PTO MISTAKE PURSUANT TO 37 C.F.R. § 1.322(a)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Enclosed, in duplicate, is a Certificate of Correction, Form PTO-SB/44, for United States Patent Number 7,226,513 issued June 5, 2007. The following Patent Office printing errors appear in the issued patent:

IN THE SPECIFICATION

The exact column and line number where the error in the issued patent is shown correctly in the application are:

Column 10, line 1 should read as "oxidizing a silicon wafer annealed under"; Please delete the second occurrence of "a silicon wafer".

Applicant submits that the above changes would not constitute new matter, and correction thereof would not require reexamination.

Pursuant to 37 C.F.R. §1.322, Applicant requests that the enclosed Certificate of Correction be approved.

Although Applicant believes that no fee is required for this Request, the Commissioner is hereby authorized to charge any additional fees which may be required for this Request to Deposit Account No. 19-0741.

Respectfully submitted,

Date JUL 31 2007

By 

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AUG 2 2007

**UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION**

PATENT NO. : 7,226,513
APPLICATION NO. : 10/645,911
DATED : 06/05/2007
INVENTOR(S) : Hisatsugu KURITA; Manabu HIRASAWA; Hiromi NAGAHAMA;
Koji IZUMOME; Takao INO; Jyunsei YAMABE; Naoya HAYAMIZU;
Naoaki SAKURAI

It is certified that an error appears or errors appear in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 10, line 1 should reads as "oxidizing a silicon wafer annealed under"

MAILING ADDRESS OF SENDER (Please do not use customer number below):

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3000 K Street NW, Suite 500
Washington, D.C. 20007-5143

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(Also Form PTO-1050)

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